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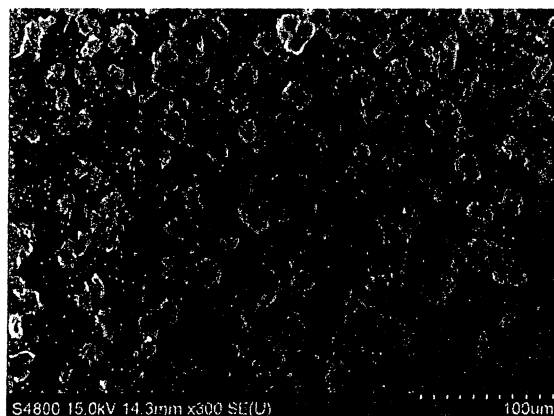
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(54) **Mg-BASED STRUCTURED MEMBER**

(57) Disclosed is an Mg-based structural material in which the surface of the base is coated with a film comprising apatite crystals as the main component thereof. The coating film and the base may be integrated with a magnesium hydroxide layer, and the surface of the coating film may be painted with a resin paint. The thickness of the coating film may be from 1 to 5  $\mu\text{m}$ . The Mg-based structural material takes a low environmental load in the production process thereof.

*Fig. 2*



**Description**

## Technical Field

**[0001]** The present invention relates to an Mg-based structural material comprising magnesium or a magnesium alloy, which is formed in a desired structured shape of parts of transportation equipment such as automobiles, IT instruments such as mobile telephones, housings of home electric appliances such as televisions, etc. More precisely, the invention relates to improvement in corrosion resistance of an Mg-based structural material.

## Background Art

**[0002]** A magnesium alloy has relatively high specific strength and its abundant resources are available, and therefore its application to lightweight parts for improving the fuel efficiency of automobiles and aircrafts is now under investigation. In addition, since the strength and the electromagnetic wave-shielding effect thereof are higher than those of plastics, it is utilized as housings for IT instruments such as typically mobile telephones and personal computers and as those for home electric appliances such as televisions. These parts are required to have high corrosion resistance in various environments.

**[0003]** On the other hand, magnesium is a chemically active substance and is therefore disadvantageous in that its corrosion resistance is low especially in acidic/neutral environments containing chloride ions. Transportation equipment and home electric appliances are exposed to rain and seawater droplets and human sweat containing chloride ions. Therefore, it is said necessary to form a highly corrosion-resistant coating film to cover them, and for some parts, to make painting in addition to the highly corrosion-resistant coating film.

**[0004]** The mainstream of conventional coating films for improving the corrosion resistance of magnesium materials is one that contains an element having a high environmental load such as chromium, manganese, fluorine or the like. Accordingly, a corrosion-resistant film is desired that is composed of elements of which the environmental load in the production process is low and of which the safety to the environment during use is high.

**[0005]** There are known reports of highly corrosion-resistant films formed through anodic oxidation in a solution that comprises mainly phosphoric acid and is composed of elements of which the environmental load is low (Patent Reference 1); however, anodic oxidation is disadvantageous in that it requires a measurable amount of power.

**[0006]** A chemical treatment solution and an electrolytic solution for anodic oxidation containing phosphoric acid, manganic acid and/or calcium oxide have been developed (Patent References 1 to 5), and the formed films have high corrosion resistance and good adhesiveness to paints. However, manganic acid is a substance that requires waste treatment, and therefore a corrosion-resistant film of which the environmental load is further low and its production method are desired.

Patent Reference 1: WO2003/080897  
 Patent Reference 2: JP-A 11-131225  
 Patent Reference 3: JP-A 2003-286582  
 Patent Reference 4: JP-A 2003-3237  
 Patent Reference 5: JP-A 2005-281717

## Disclosure of the Invention

## Problems that the Invention is to Solve

**[0007]** In view of the situation as above, an object of the present invention is to provide an Mg-based structural material having a corrosion-resistant film composed of environment-safe elements. Another object is to provide its production method in which the environmental load for its production is low.

## Means for Solving the Problems

**[0008]** In the invention, for the purpose of attaining the above-mentioned object, the coating film that serves as the corrosion-resistant film comprises, as the main component thereof, apatite having high thermodynamic stability among calcium phosphate of which the environmental load is low. Concretely, the invention is as follows:

First, the Mg-based structural material is **characterized in that** the surface of the base thereof is coated with a film comprising apatite crystals as the main component thereof.

Secondly, in the Mg-based structural material of the first aspect, the coating film and the base are integrated via a

magnesium hydroxide layer.

Thirdly, in the Mg-based structural material of the first or second aspect, the surface of the coating film is painted with a resin paint.

Fourthly, in the Mg-based structural material of any one of the first to third aspects, the thickness of the coating film is from 1 to 5  $\mu\text{m}$ .

**[0009]** The Mg-based structural material production method relates to production of the above-mentioned Mg-based structural material, which is **characterized in that** the base formed in a desired shape is dipped in an aqueous solution containing a phosphate ion and a non-chloride calcium ion dissolved in a supersaturation state, thereby precipitating a coating film comprising apatite crystals as the main component thereof, on the surface of the base.

**[0010]** In the Mg-based structural material production method of the above aspect, the calcium ion in the aqueous solution is prepared by dissolution of a calcium chelate compound therein.

#### Advantage of the Invention

**[0011]** Calcium phosphate such as typically apatite has a low solubility in neutral environments and is not corroded by a chloride ion. Among various types of crystal structures that calcium phosphate may have, apatite is in the form of a crystal structure having high thermodynamic stability, and therefore its solubility in an aqueous solution is lower than that of other calcium phosphate. Calcium phosphate is a main component of the bone of a living body, and is therefore a highly environment-safe material composed of elements of which the environmental load is low.

**[0012]** From the above-mentioned characteristics, it may be taken into consideration to provide a highly corrosion-resistant magnesium material having a low environmental load by precipitating calcium phosphate such as typically apatite, and especially apatite on the surface of magnesium. Further, formation of a film that comprises apatite as the main component thereof in an aqueous solution, if possible, could reduce the environmental load in the production process.

**[0013]** However, magnesium is an element that inhibits crystallization of apatite, and the related technical knowledge is that direct precipitation of apatite from an aqueous solution on the surface of a magnesium material would be impossible.

**[0014]** The present invention has broken down the technical knowledge.

**[0015]** The Mg-based structural material of the invention has a coating film comprising apatite as the main component thereof, and is therefore effective for preventing the corrosion of the magnesium or magnesium alloy base thereof.

**[0016]** The Mg-based structural material is composed of environment-safe elements alone, and is therefore effective for reducing the environmental load in recycling the magnesium material.

**[0017]** Moreover, the solution for coating film formation is an aqueous solution containing environment-safe elements alone, and is therefore effective for securing the environmental protection around factories and for reducing the waste treatment cost.

**[0018]** In general, a phosphate-containing coating film has high adhesiveness to paint and is therefore expected to have excellent paint adhesiveness to the coating film comprising an apatite crystal as the main component thereof; and in addition, since the apatite crystal is a transparent or white crystal, another advantage is expected that the coating film does not detract from coloration of the overcoating paint.

#### Brief Description of the Drawings

##### **[0019]**

Fig. 1 is a graph showing the XRD patterns of samples A to D.

Fig. 2 is an electron microscopic picture of the surface of sample B.

Fig. 3 is an electron microscopic picture of the cross section of sample B.

Fig. 4 is an electron microscopic picture of the surface of sample C.

Fig. 5 is an electron microscopic picture of the cross section of sample C.

Fig. 6 is a graph showing the XRD patterns of samples H and I.

Fig. 7 is a graph showing the XRD patterns of samples K to M.

Fig. 8 is an electron microscopic picture of the surface of sample H.

Fig. 9 is a graph showing the XRD patterns of samples N to P.

Fig. 10 is a graph showing the XRD patterns of samples Q to T.

Fig. 11 is a graph showing the XRD patterns of samples U to W.

Fig. 12 is a photographic picture of the surface of sample C of which the surface treatment layer and the corrosion product were removed after 96-hour dry-wet cycle test.

Fig. 13 is a photographic picture of the surface of sample J of which the surface treatment layer and the corrosion

product were removed after 24-hour dry-wet cycle test.

Fig. 14 is a photographic picture of the surface of sample K of which the surface treatment layer and the corrosion product were removed after 24-hour dry-wet cycle test.

Fig. 15 is a photographic picture of the surface of just-polished sample of which the surface treatment layer and the corrosion product were removed after 24-hour dry-wet cycle test.

Fig. 16 shows anode polarization curves in 3.5 wt.% NaCl solution of samples C, J, K and just-polished sample.

Fig. 17 is a graph showing anode current density at -1.45 V (SCE).

#### Mode for Carrying out the Invention

**[0020]** In the invention, the coating film that comprises an apatite crystal as the main component thereof and covers the surface of the base is a film formed through precipitation of the phosphate ion and the calcium ion contained in the treatment solution on the surface of the base as an apatite crystal thereon, and therefore can be formed irrespective of the composition of the base. Accordingly, the composition of the base is not specifically defined, and may be pure magnesium or a magnesium alloy.

**[0021]** The coating film is formed through dipping treatment in an aqueous solution, and even though the surface configuration of the base is a complicated one, it does not have any influence on the coating film.

**[0022]** The coating film comprises, as described in the above, an apatite crystal as the main component thereof and has, depending on the dipping treatment condition, a layer comprising crystalline  $\text{Mg}(\text{OH})_2$  as the main component thereof, in the boundary to the base. The solubility in a salt solution of the apatite crystal having a thermodynamically stable crystal structure is extremely low. The solubility of the crystalline  $\text{Mg}(\text{OH})_2$  is extremely lower than that of the amorphous  $\text{Mg}(\text{OH})_2$  formed on the surface of a magnesium material in air. Accordingly, the Mg-based structural material of the invention can exhibit high corrosion resistance as compared with a magnesium material having a coating film formed through oxidation in air.

**[0023]** The surface treatment solution for producing the Mg-based structural material of the invention is an aqueous solution containing a calcium chelate compound and a phosphate ion and having pH of from 5 to 13.

**[0024]** The calcium compound capable of dissolving a high-concentration calcium ion in a broad pH range includes a calcium compound of a chelate such as EDTA, NTA, HEDTE, aminopolycarboxylic acid or the like, etc. So far as it is a neutral to acidic treatment solution, also usable is an inorganic salt such as calcium hydroxide, calcium nitrate, calcium carbonate, calcium acetate, calcium dihydrogenphosphate, calcium thiosulfate, etc. Adding a chelating agent along an inorganic salt increases the calcium ion concentration. In such a manner, when a chelate compound is employed as the calcium source, a relatively high-concentration calcium ion can be dissolved not only in an acidic aqueous solution but also in an alkaline aqueous solution.

**[0025]** An alkaline aqueous solution containing a chelating agent such as EDTA or the like is used for smut removal from the surface of an acid-washed magnesium material. Therefore, when the concentration of the chelating agent is too high, then the surface of the base, magnesium may tend to be roughened. For example, when the EDTA concentration is higher than  $2.5 \times 10^{-1}$  M for pure magnesium, then the surface of the magnesium base may be greatly roughened and a coating film comprising calcium phosphate as the main component thereof could not homogeneously cover the surface.

**[0026]** On the other hand, the presence of the chelating agent promotes degreasing of the base surface and removal of the release agent, oxide film and smut from the surface along with film formation, and is therefore expected to reduce the impurities in the coating film to be formed.

**[0027]** The inorganic phosphate salt constituting the treatment solution includes various alkali salts, ammonium salts, alkaline earth orthodihydrogen salts and the like, such as potassium dihydrogenphosphate, disodium hydrogenphosphate, ammonium dihydrogenphosphate, diammonium hydrogenphosphate, calcium monohydrogenphosphate, etc.

**[0028]** When the calcium salt and phosphate salt concentration is less than  $5 \times 10^{-4}$  M, then the apatite crystal precipitation speed may tend to be extremely low. In this case, the dipping time will have to be prolonged.

**[0029]** Accordingly, for the purpose of controlling the pH of the treatment solution prepared from a calcium compound and an inorganic phosphate salt, an alkaline solution of sodium hydroxide, potassium hydroxide, ammonia or the like is used. The pH range to be controlled is preferably within a range of pH 5 to pH 13. Within the pH range, the magnesium base dipped in the treatment solution may start to dissolve, and owing to the pH increase through the dissolution reaction, the pH around the surface of the magnesium base could be pH 7 or more at which the apatite crystal phase could be stable. Even in the pH range of pH 11 or more in which magnesium hydroxide is insoluble, the apatite crystal phase is still stable, and therefore apatite can be precipitated on the surface of the magnesium base.

**[0030]** The thickness of the coating film that comprises an apatite crystal as the main component thereof is preferably from  $1 \times 10^{-2}$   $\mu\text{m}$  to  $5 \times 10^1$   $\mu\text{m}$ . More preferably, the lowermost limit is at least  $1 \times 10^{-1}$   $\mu\text{m}$ , even more preferably at least  $5 \times 10^{-1}$   $\mu\text{m}$ , still more preferably at least 1  $\mu\text{m}$ . The uppermost limit is more preferably at most  $2.5 \times 10^1$   $\mu\text{m}$ , even more preferably at most 1  $\times 10^1$   $\mu\text{m}$ , still more preferably at most 5  $\mu\text{m}$ . When the coating film is too thin, then it

could not uniformly coat the surface of the base and the corrosion resistance may be poor; but when too thick, the film may readily peel off from the base surface.

**[0031]** The Mg-based structural material of the invention is used in various applications. It may be used for parts of automobiles and two-wheeled vehicles, and housings of mobile telephones, personal computers, video cameras, etc.

**[0032]** The Mg-based structural material of the invention exhibits excellent corrosion resistance as it is just treated, but for further improving the corrosion resistance thereof, or for improving the aesthetic appearance of the magnesium material, the Mg-based structural material may be painted, if desired. Not specifically defined, the paint may be either a water-bases paint or a solvent-bases paint. Not also specifically defined, the painting method may be any known method of dip painting, spray painting, electrodeposition painting, etc.

#### Examples

**[0033]** As shown in Table 1, a base of pure magnesium of which the surface had been finished with a 0.1- $\mu\text{m}$  alumina lapping film was dipped in a solution prepared by adding 1 N NaOH solution to an aqueous solution of 50 mM Ca-EDTA/ 50 mM  $\text{KH}_2\text{PO}_4$  in a ratio of 0, 1/40, 1/20 or 3/40 by volume to the latter so as to have a controlled pH value, and statically kept therein at 95°C for 8 hours to thereby prepare samples A to D.

**[0034]** Fig. 1 shows the XRD patterns of the treated samples A to D. All the samples gave peaks of hydroxyapatite (HAp) and  $\text{Mg}(\text{OH})_2$  (Brucite form). With the increase in the pH of the treatment solution, the HAp peak intensity increased and the  $\text{Mg}(\text{OH})_2$  (Brucite) peak intensity decreased.

**[0035]** Figs. 2 to 5 each show the electron microscopic picture of the surface and the cross section of Samples B and C. It is confirmed that in every sample, the surface is uniformly covered with an apatite crystal. The apatite is a tabular or needle-like crystal having a size of from 1  $\mu\text{m}$  to 10  $\mu\text{m}$  or so. Through cross section observation, EDS analysis and XRD measurement, it is known that the coating film is composed of a layer comprising, as the main component thereof, apatite crystals having a high concentration of Ca, P and O, and a boundary layer comprising, as the main component thereof,  $\text{Mg}(\text{OH})_2$  having a high concentration of O and Mg. In some samples like sample B, the  $\text{Mg}(\text{OH})_2$  boundary layer is extremely thin so that it could not be definitely observed through SEM, or is absent. The thickness of the formed film is shown in Table 1. With the increase in the pH of the treatment solution, the thickness tended to increase.

**[0036]** These results confirm that the size of the apatite crystal and the thickness of the coating film can be controlled through pH control of the treatment solution.

Table 1

Sample Code		A	B	C	D
Ca-EDTA Concentration	mM			50	
$\text{KH}_2\text{PO}_4$ Concentration	mM			50	
Addition Ratio of 1N NaOH (*1)		0	1/40	1/20	3/40
pH of Treatment Solution (*2)	pH	5.3-5.5	6.1-6.5	7.1-7.4	11.0-11.5
Treatment Time	h			8	
Apatite Formation (*3)		○	○	○	○
Film Thickness	$\mu\text{m}$	1.3	1.5	2.5	2.3
*1 Added amount in terms of volume relative to the volume of the Ca-EDTA/ $\text{KH}_2\text{PO}_4$ solution taken as the denominator.					
*2 Value measured with a pH test paper. The right and left values of the range indicate the lowermost and uppermost limit of the error range.					
*3 ○: Apatite crystal-derived peaks are observed definitely on the XRD spectrum.					
△: Apatite crystal-derived peaks are extremely small on the XRD spectrum.					
×: No apatite crystal-deived peak is observed on the XRD spectrum.					

## Example 2

**[0037]** As shown in Table 2, a pure magnesium base that had been surface-finished in the same manner as in Example 1 was dipped in an aqueous solution of 50 mM Ca-EDTA/50 mM  $\text{KH}_2\text{PO}_4$  prepared by adding 1 N NaOH thereto in a ratio of 1/40 by volume to the former so as to have a controlled pH value, and statically kept therein at 95°C for 24, 96 or 168 hours to thereby prepare samples E to G. In addition, a pure magnesium base that had been surface-finished in the same manner as in Example 1 was dipped in an aqueous solution of 50 mM Ca-EDTA/50 mM  $\text{KH}_2\text{PO}_4$  prepared by adding 1 N NaOH thereto in a ratio of 1/20 by volume to the former so as to have a controlled pH value, and statically kept therein at 95°C for 2, 4, 16, 24, 96 or 168 hours to thereby prepare samples H to M. Fig. 6 shows the XRD patterns of the samples H and I treated with a solution having a pH of from 7.1 to 7.4; and Fig. 7 shows the XRD patterns of the surfaces of the samples K to M treated with a solution having a pH of from 7.1 to 7.4. Treated for a different period of time, the samples gave HAp peaks; and the samples treated for a longer period of time additionally gave  $\text{Mg}(\text{OH})_2$  (Brucite) peaks. On the other hand, the sample H treated for 2 hours gave no peak of  $\text{Mg}(\text{OH})_2$  (Brucite).

**[0038]** With the increase in the treatment time, the HAp peaks became sharper and the intensity thereof significantly increased. The  $\text{Mg}(\text{OH})_2$  peak intensity also increased with the increase in the treatment time. On the other hand, the base magnesium peak intensity significantly decreased with the increase in the treatment time. The samples E to G treated with a solution having a pH of from 6.1 to 6.5 gave the same results.

**[0039]** The thickness of the coating film, as determined through observation of the cross section of the sample, is shown in Table 2. The thickness of the coating film thinner than 1  $\mu\text{m}$  is a value presumed from the relationship between the treatment time and the film thickness. Even when the treatment time is 2 hours and is short, the apatite crystal uniformly covers the surface of the base, as shown in Fig. 8, and with the increase in the treatment time, the thickness of the apatite crystal layer tended to increase. When the treatment time is 96 hours or more and is long, the apatite crystal precipitation amount increased, but in many cases, a part or all of the coating film peeled from the surface of the base.

**[0040]** These results indicate that the apatite crystal layer can be formed even when the treatment time is short, and that the apatite crystal precipitation amount can be varied by changing the treatment time and the film thickness can be thereby controlled. However, in case where the treatment time is too long and when the film thickness is more than 50  $\mu\text{m}$ , then the coating film is often peeled.

Table 2

Sample Code		E	F	G	H	I	J	K	L	M
Ca-EDTA Concentration	mM		50					50		
$\text{KH}_2\text{PO}_4$ Concentration	mM		50					50		
Addition Ratio of 1 N NaOH (*1)	-		1 / 40					1/20		
pH of Treatment Solution (*2)	pH		6.1-6.5					7.1-7.4		
Treatment Time	h	24	96	168	2	4	16	24	96	168
Apatite Formation (*3)		○	○	○	○	○	○	○	○	○
Film Thickness	$\mu\text{m}$	2	75	90	0.7	1.5	3.7	5	220	550

\*1 Added amount in terms of volume relative to the volume of the Ca-EDTA/ $\text{KH}_2\text{PO}_4$  solution taken as the denominator.

\*2 Value measured with a pH test paper. The right and left values of the range indicate the lowermost and uppermost limit of the error range.

\*3 ○: Apatite crystal-derived peaks are observed definitely on the XRD spectrum.

△: Apatite crystal-derived peaks are extremely small on the XRD spectrum.

×: No apatite crystal-derived peak is observed on the XRD spectrum.

## Example 3

**[0041]** As shown in Table 3, a pure magnesium base that had been surface-finished in the same manner as in Example 1 was dipped in an aqueous solution of 250 mM Ca-EDTA/250 mM  $\text{KH}_2\text{PO}_4$  prepared by adding 1 N NaOH thereto in a ratio of 1/40, 1/20 or 3/40 by volume to the former so as to have a controlled pH value, and statically kept therein at 95°C for 8 hours to thereby prepare samples N to P. In the treatment solution used herein, the phosphate ion and the calcium ion concentration was 5 times that of the solution used in Example 1 and Example 2.

**[0042]** Fig. 9 shows the XRD patterns of the treated samples N to P. All the samples gave HAp peaks of hydroxyapatite. With the increase in the pH of the treatment solution, the HAp peak intensity increased. Samples O and P gave  $\text{Mg}(\text{OH})_2$  (Brucite) peaks; however, sample N for which the pH of the treatment solution was relatively low did not give a definite peak. The  $\text{Mg}(\text{OH})_2$  peaks of samples O and P were extremely small as compared with those of samples A to D. These indicate that the magnesium hydroxide layer is difficult to be formed in the solution having a high calcium ion and phosphate ion concentration. The thickness of the formed film is shown in Table 3.

**[0043]** When compared with that of the surface treated with 50 mM Ca-EDTA/50 mM  $\text{KH}_2\text{PO}_4$  solution in Example 1, the HAp peak intensity of the surface treated with the 250 mM solution was higher. On the other hand, the  $\text{Mg}(\text{OH})_2$  peak intensity of the surface treated with the 250 mM solution was lower.

**[0044]** These results indicate that the increase in the phosphate ion and calcium ion concentration in the treatment solution increases the apatite crystal precipitation amount and retards the growth of the boundary layer,  $\text{Mg}(\text{OH})_2$  layer.

Table 3

Sample Code		N	O	P
Ca-EDTA Concentration	mM		250	
$\text{KH}_2\text{PO}_4$ Concentration	mM		250	
Addition Ratio of 1N NaOH (*1)	-	1 /40	1/20	3/40
pH of Treatment Solution (*2)	pH	6.1	6.1-6.2	6.5-7.0
Treatment Time	h		8	
Apatite Formation (*3)		○	○	○
Film Thickness	$\mu\text{m}$	1.7	1.8	2.7
*1 Added amount in terms of volume relative to the volume of the Ca-EDTA/ $\text{KH}_2\text{PO}_4$ solution taken as the denominator.				
*2 Value measured with a pH test paper. The right and left values of the range indicate the lowermost and uppermost limit of the error range.				
*3 ○: Apatite crystal-derived peaks are observed definitely on the XRD spectrum.				
△: Apatite crystal-derived peaks are extremely small on the XRD spectrum.				
×: No apatite crystal-derived peak is observed on the XRD spectrum.				

## Example 4

**[0045]** As shown in Table 4, an alloy base of AZ31, AZ61, AZ91 or Mg-1.0 Al, of which the surface had been finished with a 0.1- $\mu\text{m}$  alumina lapping film, was dipped in an aqueous solution of 50 mM Ca-EDTA/50 mM  $\text{KH}_2\text{PO}_4$ , and statically kept therein at 95°C for 8 hours to thereby prepare samples Q to T. Fig. 10 shows the XRD patterns of samples Q to T. All the samples gave HAp peaks. With the increase in the Al concentration in the AZ series alloys, the relative peak intensity of HAp to the base alloy increased. On the other hand, the samples gave no definite peak of  $\text{Mg}(\text{OH})_2$  (Brucite). These indicate that the easiness in the magnesium hydroxide layer formation differs depending on the kind of the base. The thickness of the coating film is shown in Table 4. The film thickness varies depending on the kind of the base alloy.

**[0046]** The above clarifies that the treatment of the invention forms a coating film comprising an apatite crystal as the main component thereof on the surface of the base, irrespective of the composition of the base, magnesium alloy. -

Table 4

Sample Code		Q	R	S	T
Base Alloy		AZ31	AZ61	AZ91	Mg-1.0 Al
Ca-EDTA Concentration	mM	50		50	
KH <sub>2</sub> PO <sub>4</sub> Concentration	mM	50		50	
Addition Ratio of 1 N NaOH (*1)	-			1 /40	
pH of Treatment Solution (*2)	pH	5.3-5.5		7.7-7.9	
Treatment Time	h	8		8	
Apatite Formation (*3)		○	○	○	○
Film Thickness	μm	15		26 , 24	4
*1 Added amount in terms of volume relative to the volume of the Ca-EDTA/KH <sub>2</sub> PO <sub>4</sub> solution taken as the denominator.					
*2 Value measured with a pH test paper. The right and left values of the range indicate the lowermost and uppermost limit of the error range.					
*3 O: Apatite crystal-derived peaks are observed definitely on the XRD spectrum. Δ: Apatite crystal-derived peaks are extremely small on the XRD spectrum. ×: No apatite crystal-derived peak is observed on the XRD spectrum.					

## Example 5

**[0047]** As shown in Table 5, a pure magnesium base of which the surface had been finished with a 0.1-μm alumina lapping film was dipped in an aqueous solution of which the Ca-EDTA and KH<sub>2</sub>PO<sub>4</sub> concentration had been so designed that the ratio of Ca/P could be the same as that, 1.67 of HAp, and statically kept therein at 95°C for 8 hours to thereby prepare samples U to W. Fig. 11 shows the XRD patterns of samples U to W. When the calcium ion concentration was 1 mM, the samples gave only trace-level HAp peaks except a HAp(002) plane-derived peak, but with the increase in the calcium ion concentration, the HAp peaks increased. This indicates that, for forming a film comprising apatite crystals as the main component thereof on the surface of the material comprising, as the main component thereof, magnesium that inhibits HAp crystal formation, the calcium ion and phosphate ion concentration in the treatment solution is preferably higher. The samples U and V for which the calcium ion and phosphate ion concentration in the treatment solution was low did not give definite Mg(OH)<sub>2</sub> peaks. This indicates that the presence of the magnesium hydroxide layer depends on the calcium ion and phosphate ion concentration in the treatment solution.

Table 5

Sample Code	unit	U	V	W
Ca-EDTA Concentration	mM	1	10	50
KH <sub>2</sub> PO <sub>4</sub> Concentration	mM	0.6	6	30
Addition Ratio of 1N NaOH (*1)		3/5000	3/500	3/100
pH of Treatment Solution (*2)	pH	6.1-6.5	8.1-8.3	8.3-8.5
Treatment Time	h	8	8	8
Apatite Formation (*3)		Δ	○	○
Film Thickness	μm	<1	1.5	2.9
*1 Added amount in terms of volume relative to the volume of the Ca-EDTA/KH <sub>2</sub> PO <sub>4</sub> solution taken as the denominator.				



(continued)

Sample Code	unit	U	V	W
*2 Value measured with a pH test paper. The right and left values of the range indicate the lowermost and uppermost limit of the error range.				
*3 ○: Apatite crystal-derived peaks are observed definitely on the XRD spectrum.				
△: Apatite crystal-derived peaks are extremely small on the XRD spectrum.				
×: No apatite crystal-derived peak is observed on the XRD spectrum.				

## Example 6

**[0048]** NaCl in an amount of 1 g/m<sup>2</sup> was deposited to the surface of the samples C, J and K shown in Table 1 and Table 2 and to a just-polished sample, and at room temperature, subjected to a dry-wet cycle test for a total of 96 hours in which the relative humidity was controlled to be from 55% to 95% and again 55% at intervals of 8 hours. The comparative sample, just-polished sample is a 0.1-μm alumina lapping-finished sample. The NaCl deposition amount of 1 g/m<sup>2</sup> is close to the NaCl deposition amount in a seaside region, and means an extremely severe corrosion environment. Even though corroded in this test, the samples are not always corroded in actual environments.

**[0049]** Fig. 12 to Fig. 15 are pictures each showing the surface of the samples C, J and K and the just-polished sample after the 96-hour dry-wet cycle test, from which the surface-treated layer and the corrosion product had been removed. After the 96-hour test, the samples C and K had small filiform corrosion at the edge thereof; however, the sample J did not have any remarkable corrosion. On the other hand, the just-polished sample was covered with filiform corrosion almost on the entire surface thereof. This clarifies that the surface treatment in the invention provides sufficient corrosion resistance against atmospheric corrosion. In addition, it is known that even a thin coating film having a thickness of less than 5 μm secures sufficient corrosion resistance.

## Example 7

**[0050]** The samples C, J and K shown in Table 1 and Table 2 and the just-polished sample were anodically polarized in a 3.5 wt.% NaCl solution at room temperature. The NaCl concentration of 3.5 wt.% is the same salt concentration as in seawater. Fig. 16 shows the polarization curves of the samples C, J and K and the just-polished sample. The anode current density at a potential of - 1.45 V (SCE) is collectively shown in Fig. 17 and Table 6. Just after the start of polarization, the current density of the just-polished sample rapidly increased, which showed an anode current density of larger than 10 mA/cm<sup>2</sup>; however, the magnesium material having the coating film of the invention had a pseudo-passive region in a potential width of several tens mV around the corrosion potential, therefore still showing a low current density of lower than 1 mA/cm<sup>2</sup> even after rapid increase in the current density owing to film breakdown.

**[0051]** These results clarify that, even in an aqueous solution containing NaCl to the same level concentration as in seawater, the magnesium material having the coating film of the invention exhibits high corrosion resistance. In addition, it is known that a thicker coating film exhibits higher corrosion resistance in an aqueous solution.

Table 6

Sample Code	C	J	K	Comparative Example
Treatment Time [h]	8	16	24	just polished
Film Thickness [μm]	2.5	3.7	5	
Anode Current at -1.45V [A cm <sup>-2</sup> ]	6.7 x 10 <sup>-4</sup>	9.7 x 10 <sup>-6</sup>	9.6 x 10 <sup>-7</sup>	7.8 x 10 <sup>-3</sup>

## Example 8

**[0052]** A water-based epoxy paint was applied to the surface of the samples H, I and C shown in Table 1 and Table 2 and to the surface of the just-polished sample, and tested in a cross-cut test (JIS K 5600-5-6). According to the JIS classification, the paint peeling ratio was evaluated. The test results are shown in Table 7. The just-polished sample was graded in GT 3, but the sample I was in GT 2. This clarifies that the coating film in the invention improves the adhesiveness to the paint. It is known that the adhesiveness to the water-based epoxy paint depends on the thickness of the coating film, and the thickness is preferably from 1 to 2 μm.

Table 7

Sample Code	H	I	C	Comparative Example
Dipping Time [h]	2	4	8	just polished
Film Thickness [ $\mu\text{m}$ ]	0.7	1.5	2.5	-
Cross-Cut Test Grading (*1)	4	2	4	3

\*1 The grading is based on JIS K 5600. The larger number indicates a larger paint peeling ratio.

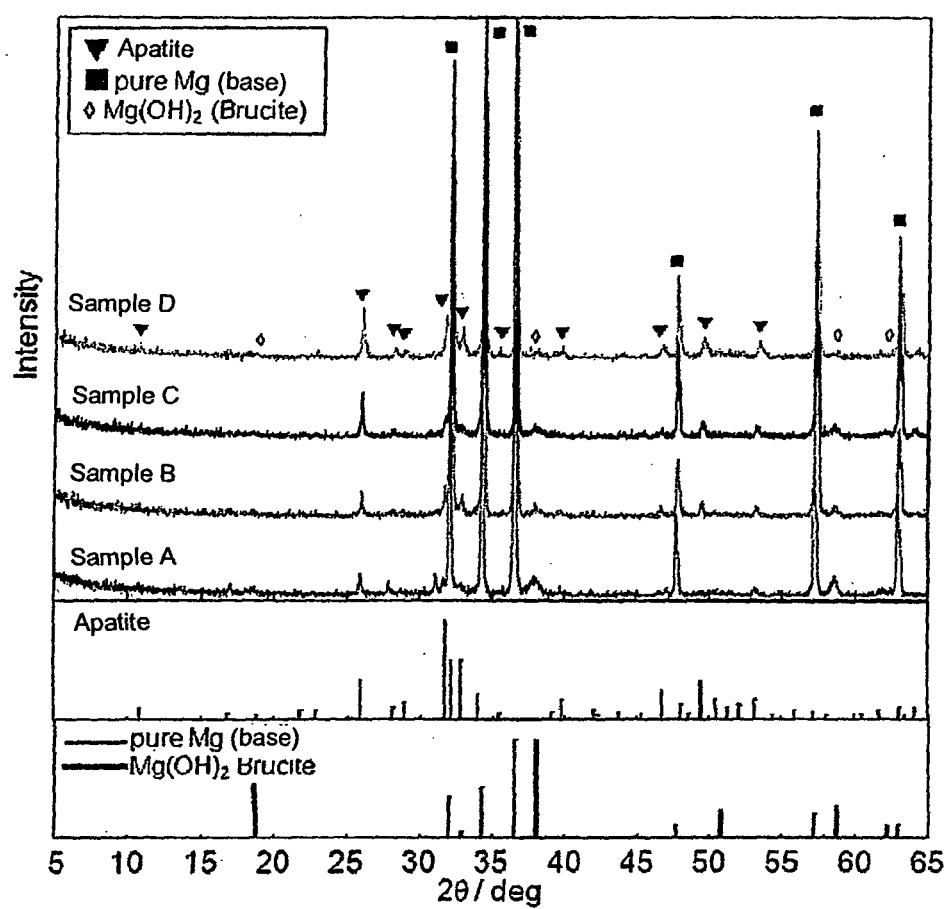
#### Industrial Applicability

**[0053]** The Mg-based structural material of the invention is used in various application. It may be used for parts of transportation equipment such as automobiles and two-wheeled vehicles, and housings of mobile telephones, personal computers, video cameras, etc. The production method for the Mg-based structural material of the invention reduces the environmental load of the production process and is effective for environmental protection.

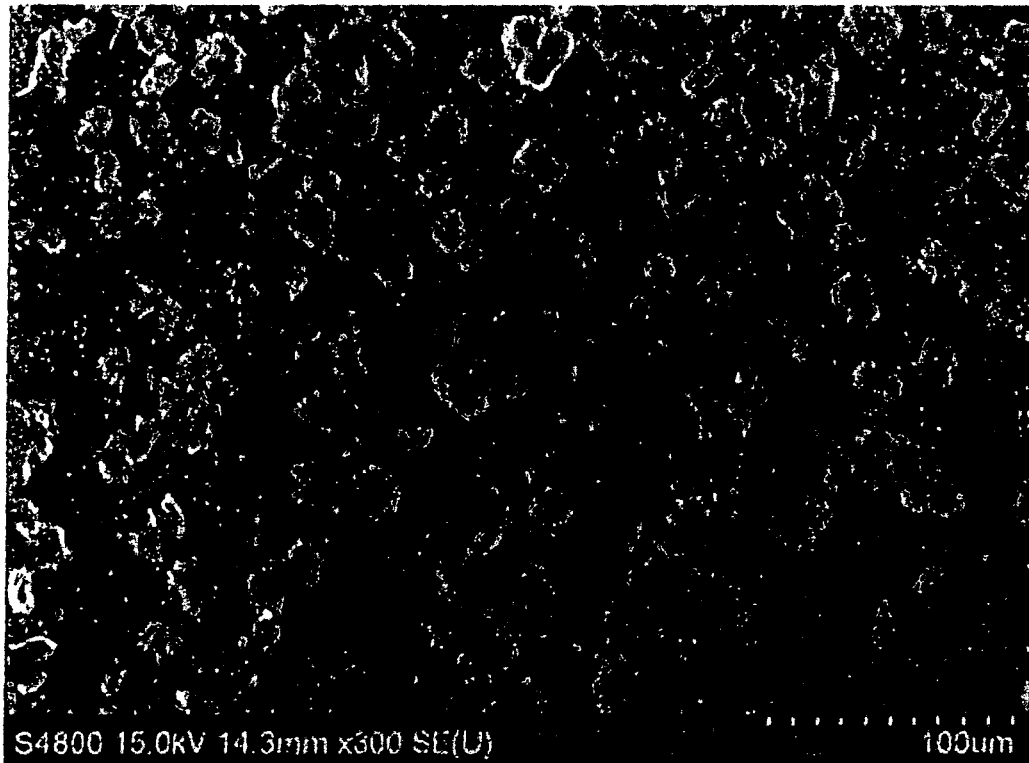
#### Claims

1. An Mg-based structural material comprising a magnesium or magnesium alloy base and formed in a desired structural shape, wherein the surface of the base is coated with a film comprising apatite crystals as the main component thereof.
2. The Mg-based structural material as claimed in claim 1, wherein the coating film and the base are integrated via a magnesium hydroxide layer.
3. The Mg-based structural material as claimed in claim 1 or 2, wherein the surface of the coating film is painted with a resin paint.
4. The Mg-based structural material as claimed in any of claims 1 to 3, wherein the thickness of the coating film is from 1 to 5  $\mu\text{m}$ .
5. A production method for the Mg-based structural material of any one of claims 1 to 4, wherein the base formed in a desired shape is dipped in an aqueous solution containing a phosphate ion and a non-chloride calcium ion dissolved in a supersaturation state, thereby precipitating a coating film comprising apatite crystals as the main component thereof, on the surface of the base.
6. The production method for the Mg-based structural material as claimed in claim 5, wherein the calcium ion in the aqueous solution is prepared by dissolution of a calcium chelate compound therein.

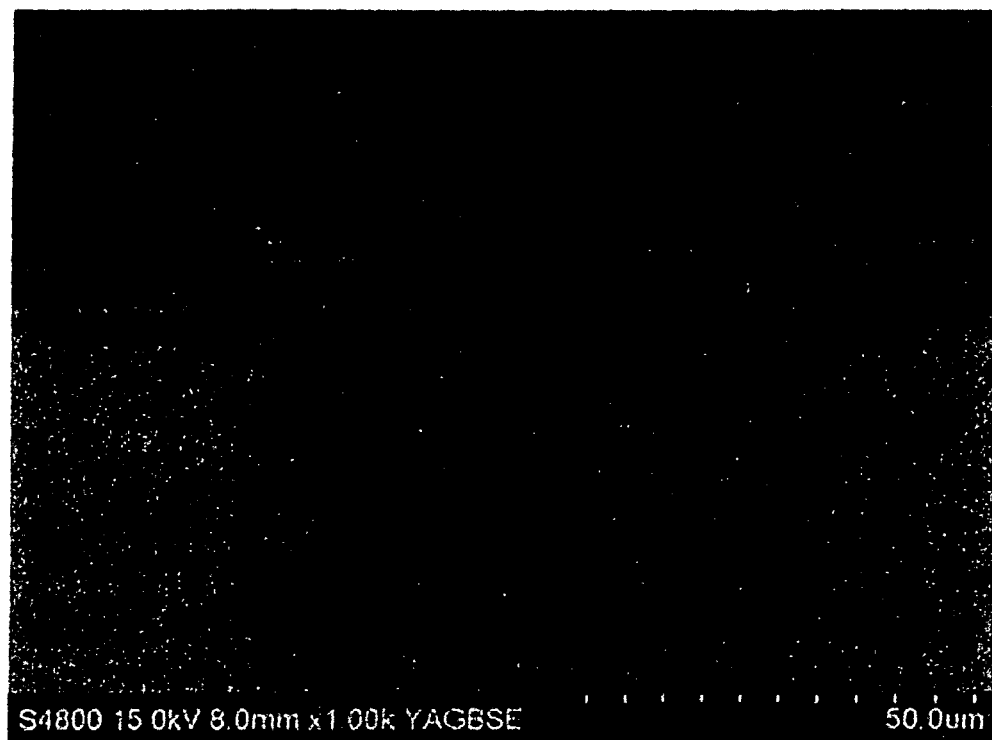
Fig. 1



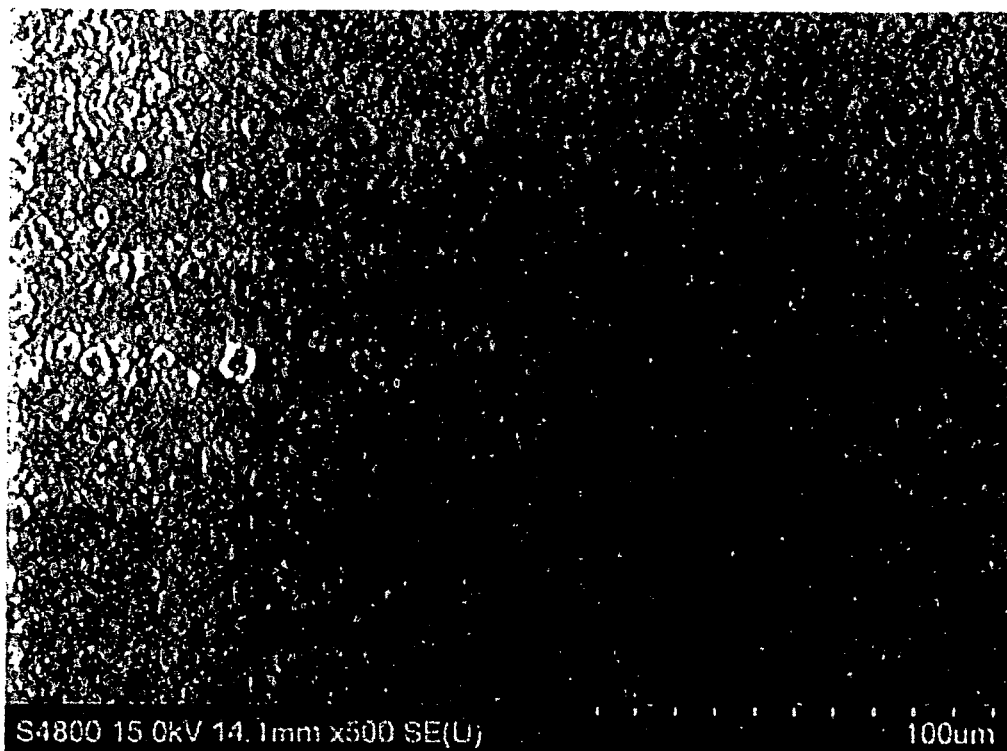
*Fig. 2*



*Fig. 3*



*Fig. 4*



*Fig. 5*

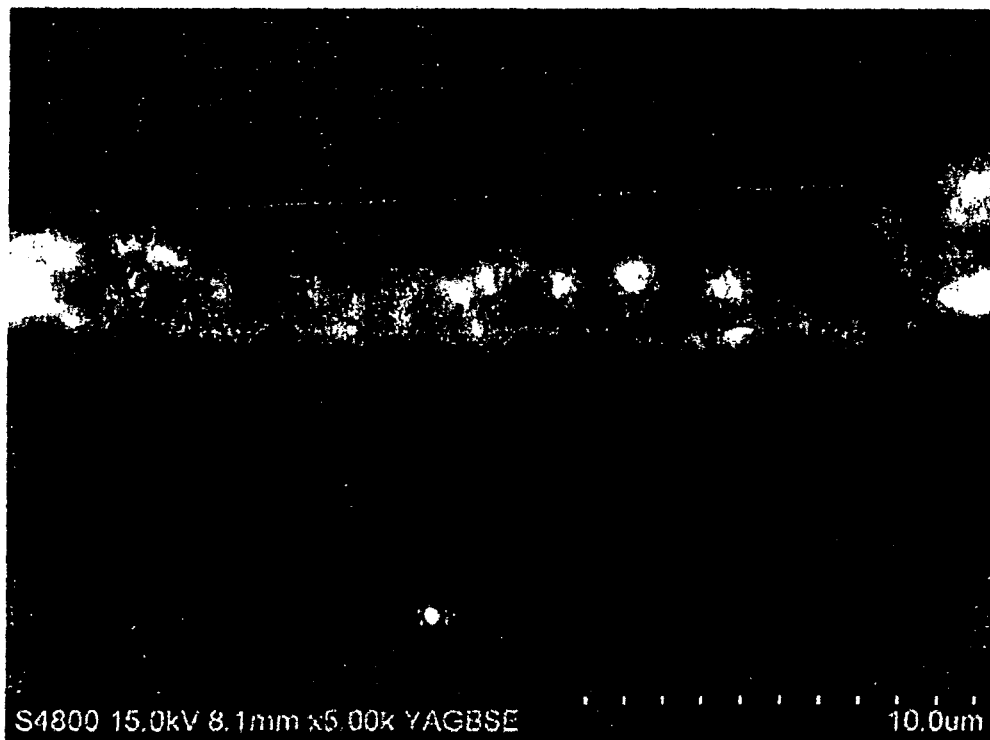


Fig. 6

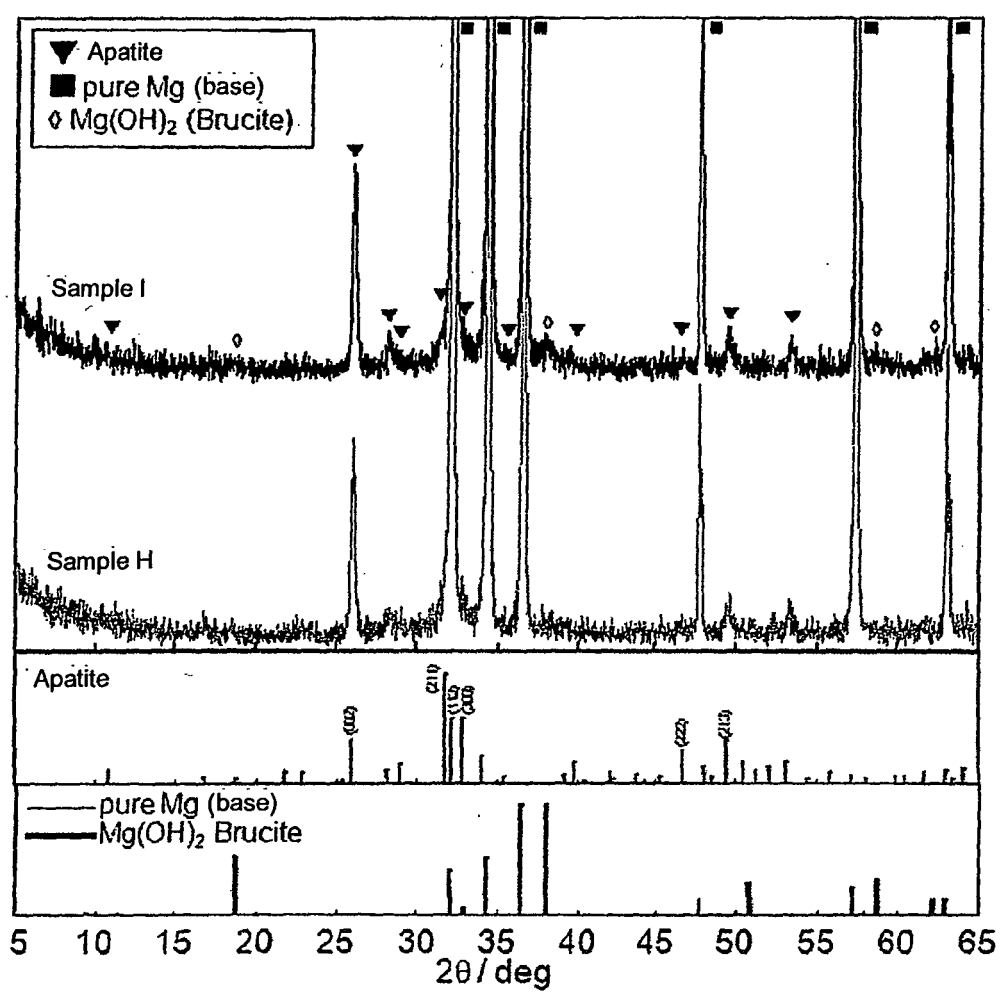
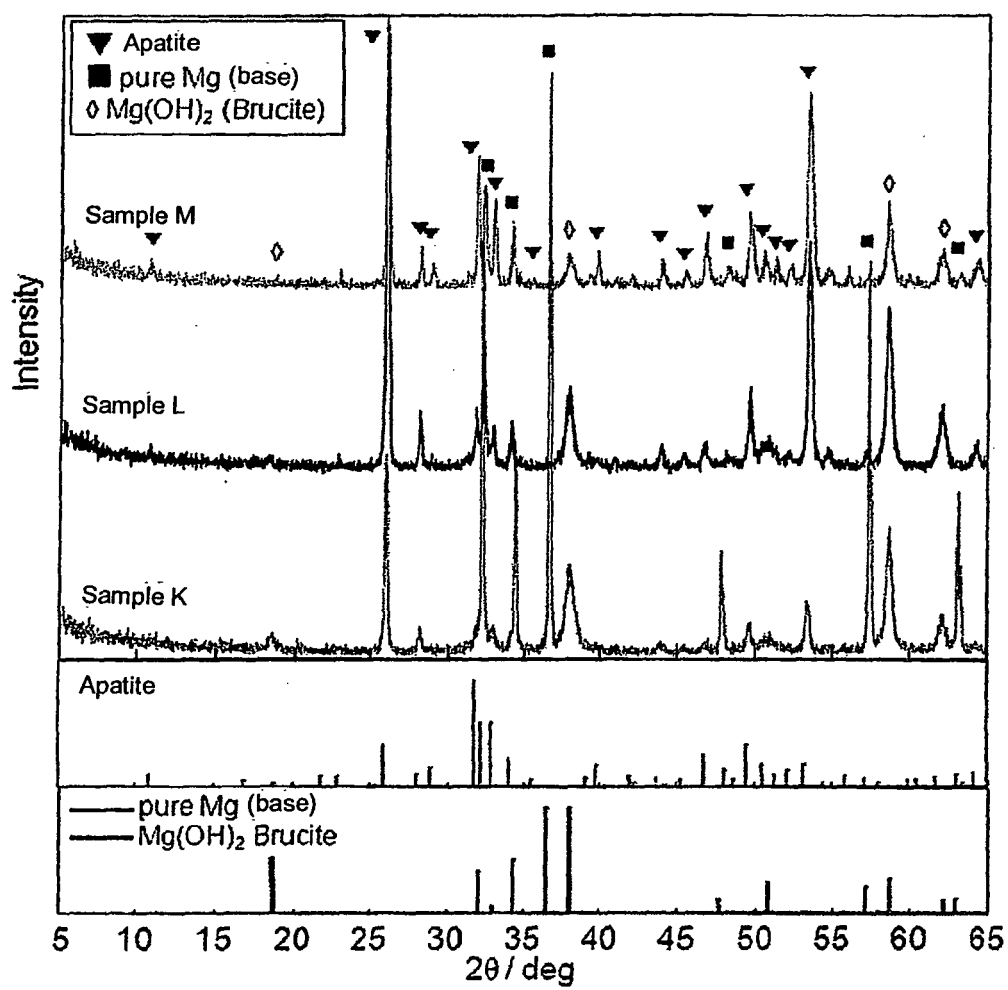




Fig. 7



*Fig. 8*

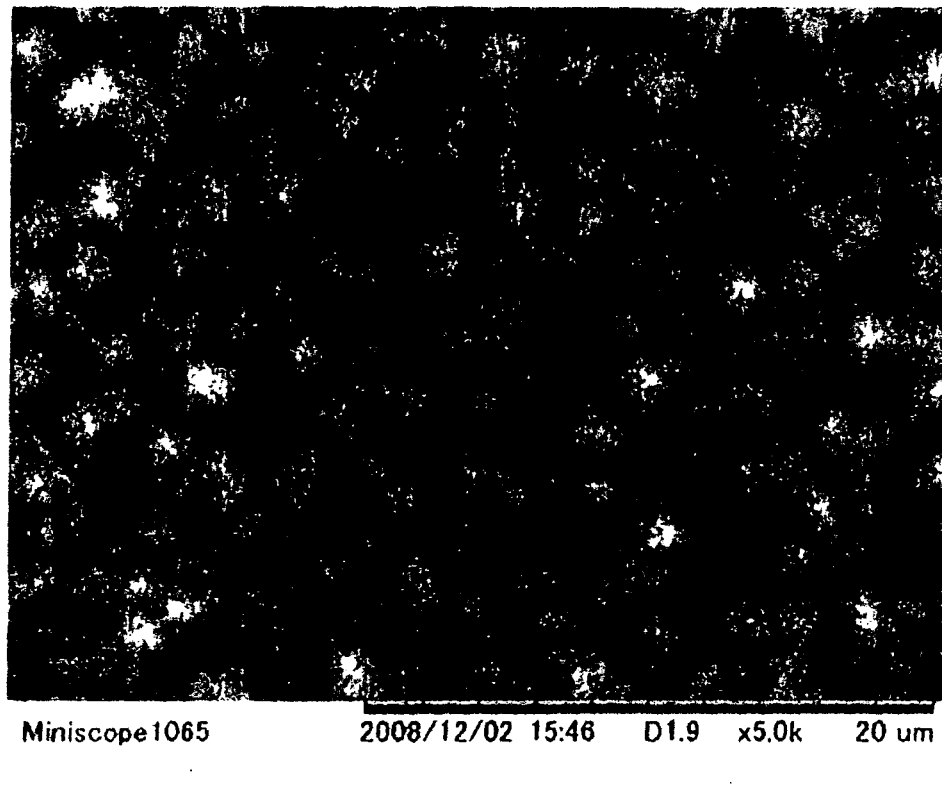


Fig. 9

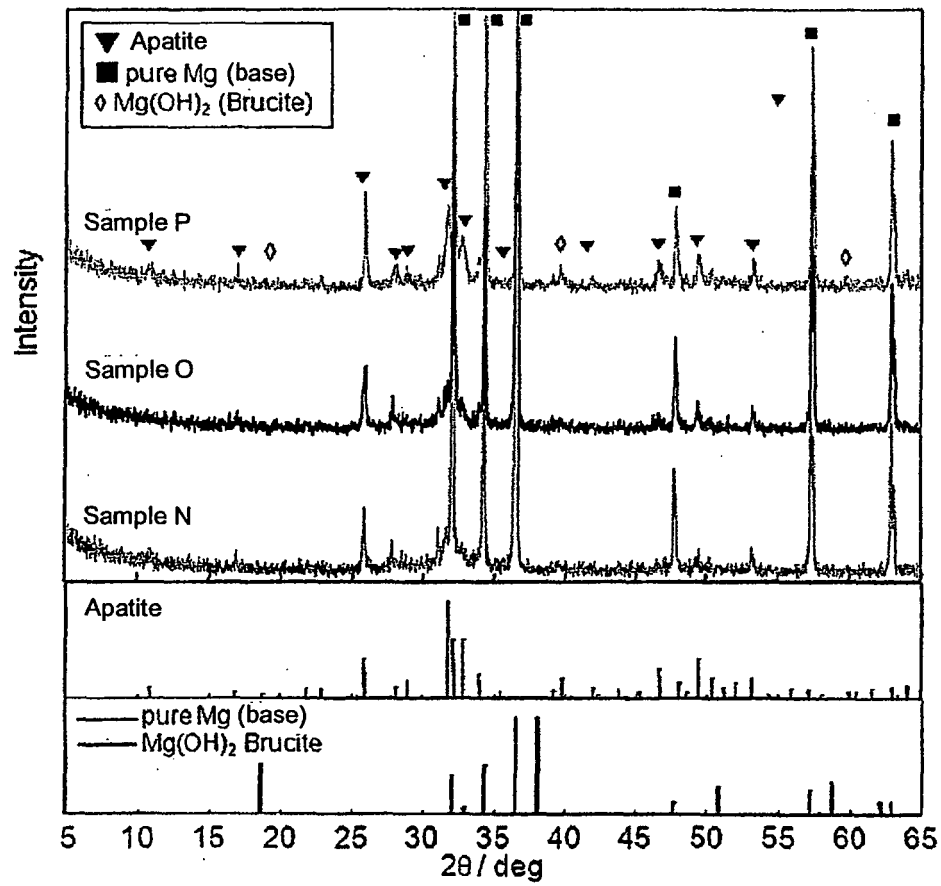


Fig. 10

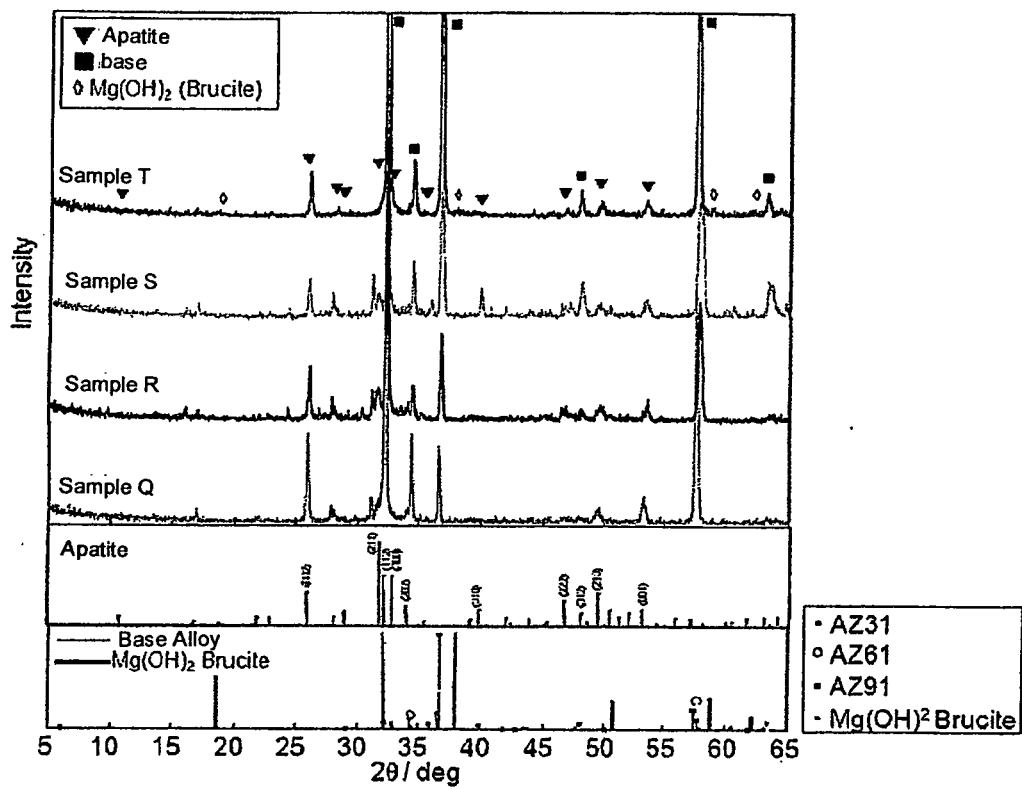
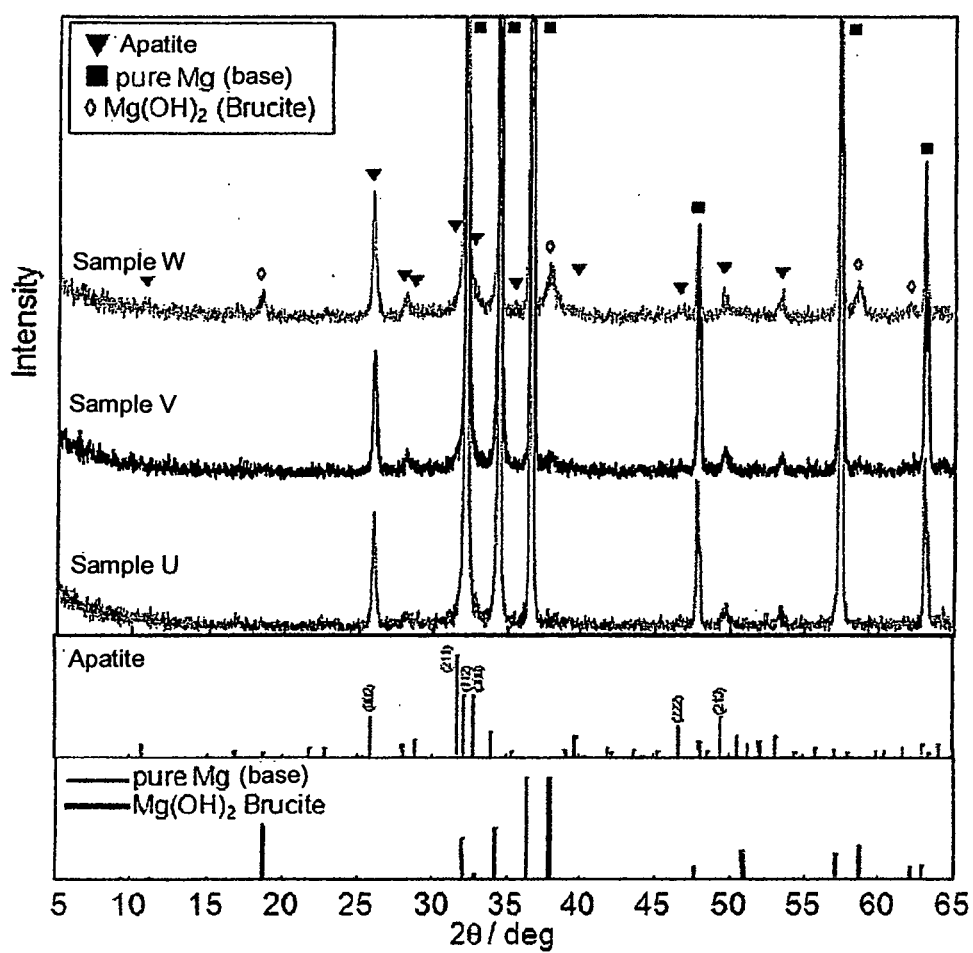
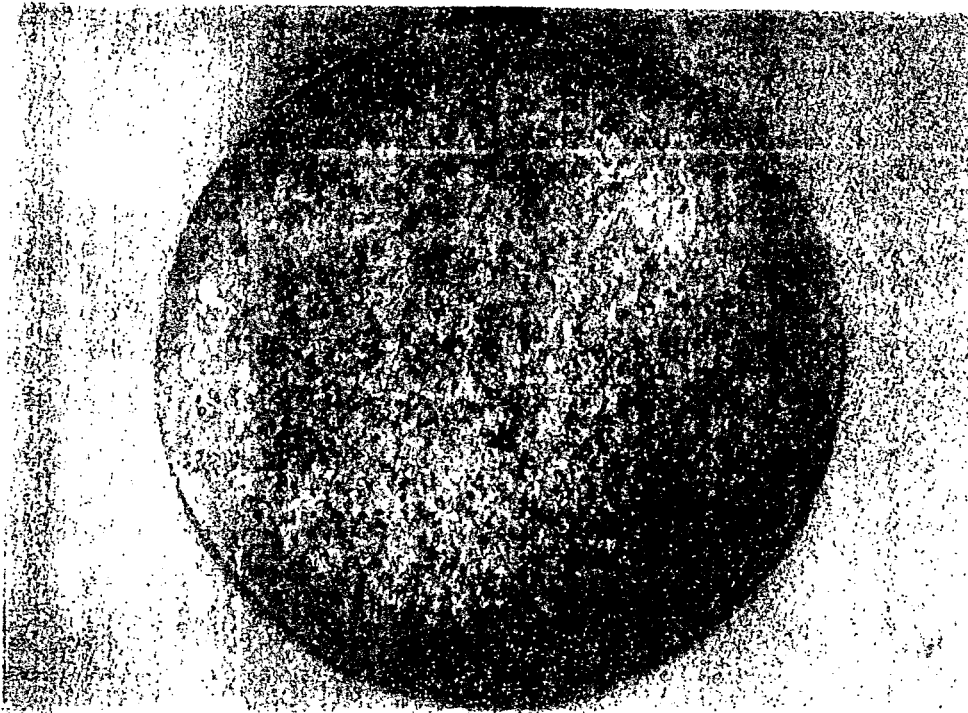


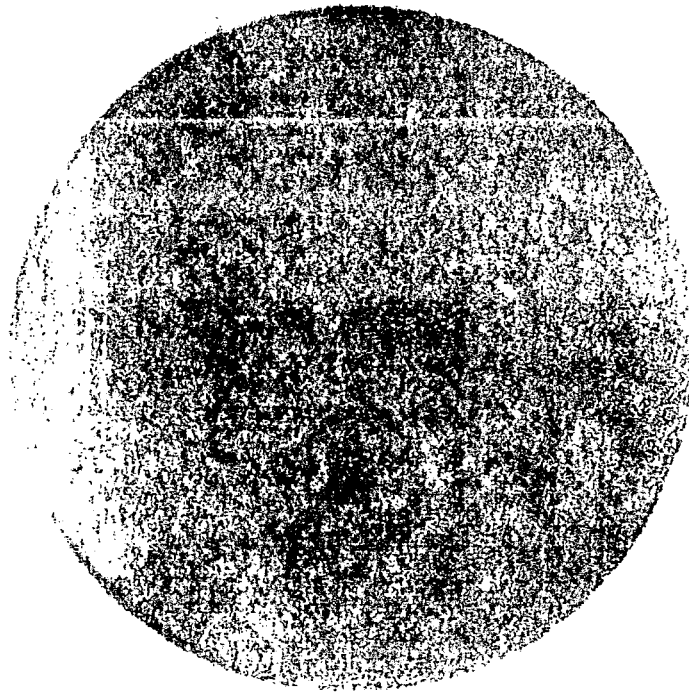
Fig. 11



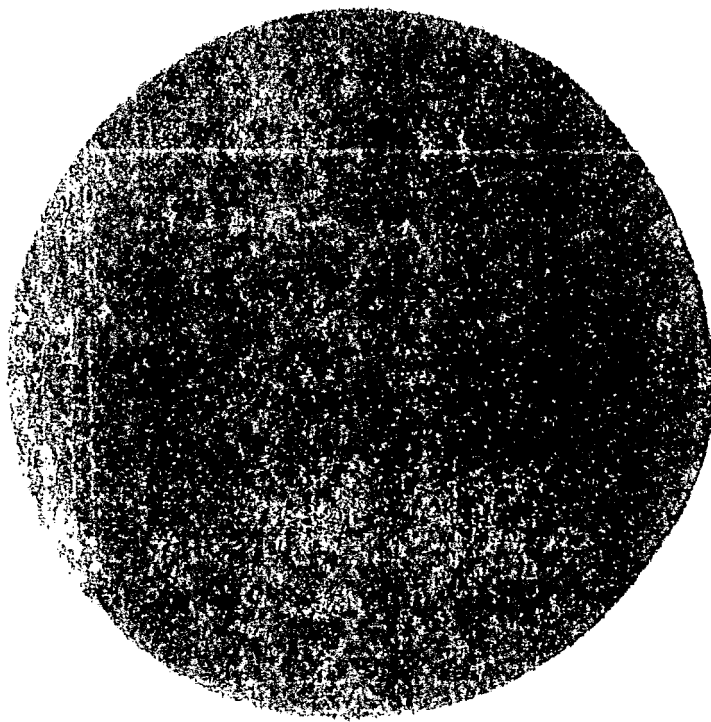
*Fig. 12*



*Fig. 13*



*Fig. 14*





*Fig. 15*

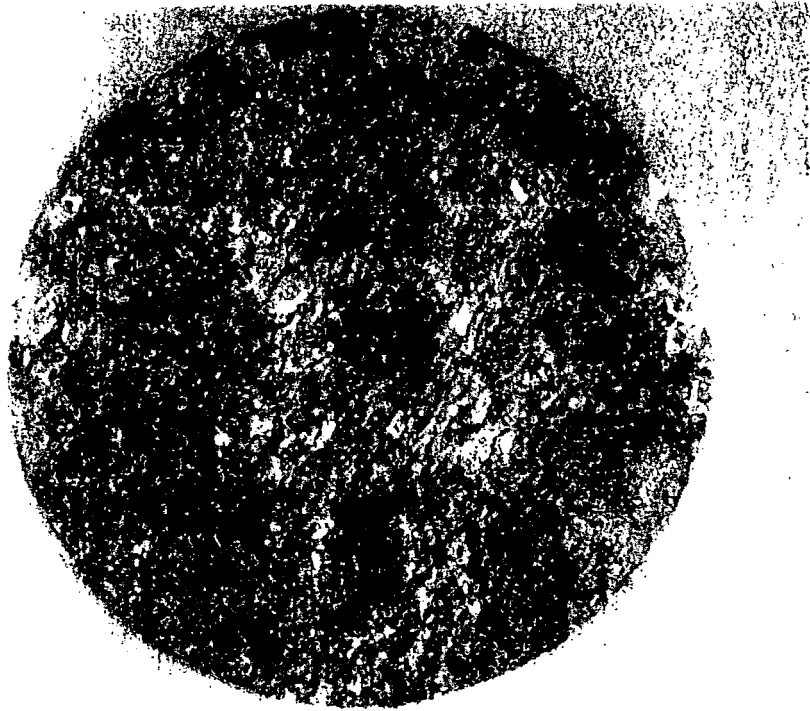


Fig. 16

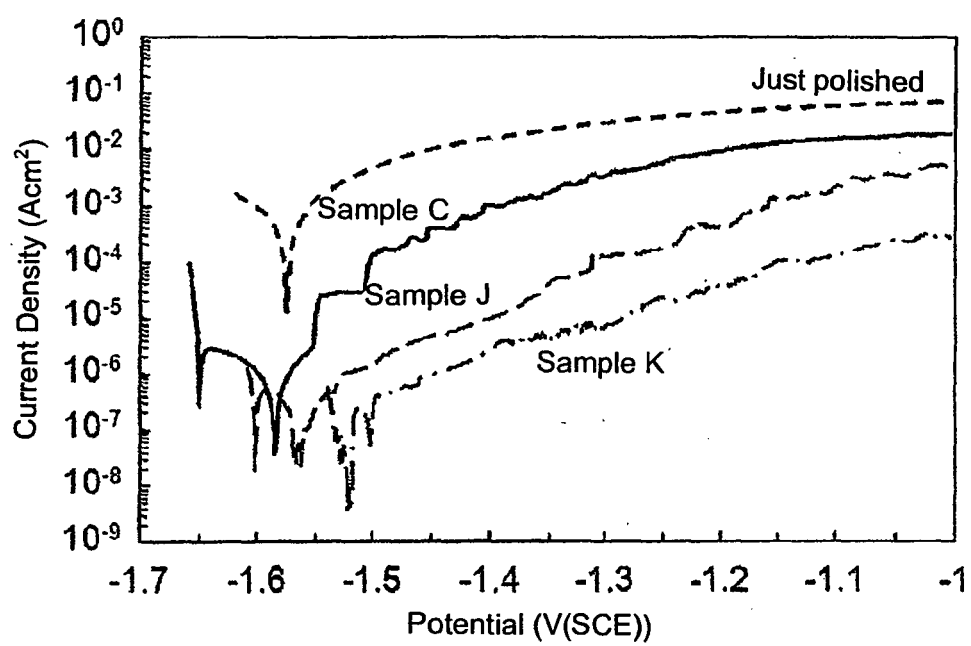
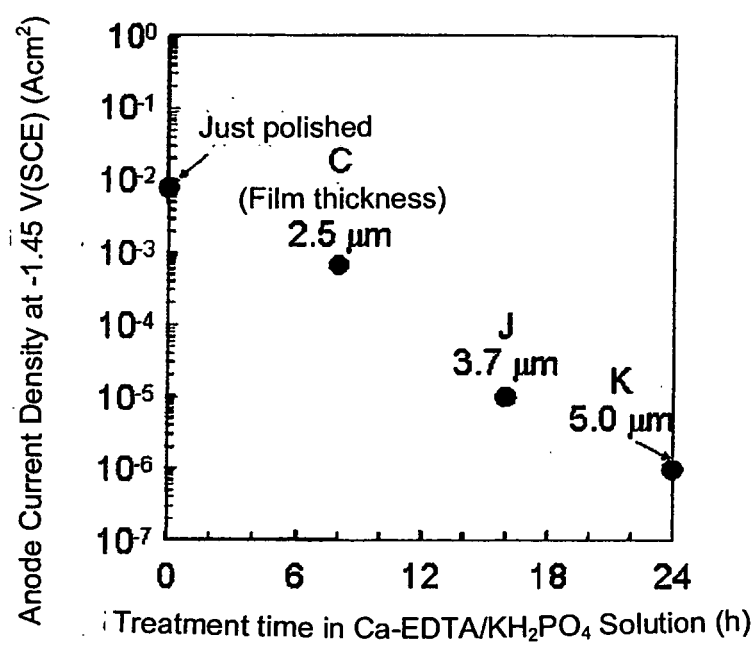


Fig. 17



## INTERNATIONAL SEARCH REPORT

International application No.

PCT/JP2010/051284

<b>A. CLASSIFICATION OF SUBJECT MATTER</b> C23C22/22(2006.01)i, C23C22/60(2006.01)i, C23C22/68(2006.01)i  According to International Patent Classification (IPC) or to both national classification and IPC		
<b>B. FIELDS SEARCHED</b> Minimum documentation searched (classification system followed by classification symbols) C23C22/00-22/86  Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Jitsuyo Shinan Koho 1922-1996 Jitsuyo Shinan Toroku Koho 1996-2010 Kokai Jitsuyo Shinan Koho 1971-2010 Toroku Jitsuyo Shinan Koho 1994-2010  Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)		
<b>C. DOCUMENTS CONSIDERED TO BE RELEVANT</b>		
Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
<u>Y</u> A	Hideyuki KUWAHARA et al., "Magnesium Gokin no Saishin no Doko Magnesiumu-sei Jinkokotsu no Kanosei", Kinzoku, 01 July 2001 (01.07.2001), vol.71, no.7, pages 656 to 660, ISSN:0368-6337	<u>1, 3, 4</u> 2, 5, 6
<u>Y</u> A	Sachiko ONO et al., "Magnesium Hyomen ni Okeru Suisan Apatite-so no Seicho Kyodo", Abstracts of the Meeting of Japan Institute, 20 October 2005 (20.10.2005), vol.109th, pages 67 to 68	<u>1, 3, 4</u> 2, 5, 6
<input type="checkbox"/> Further documents are listed in the continuation of Box C. <input type="checkbox"/> See patent family annex.		
* Special categories of cited documents: "A" document defining the general state of the art which is not considered to be of particular relevance "E" earlier application or patent but published on or after the international filing date "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or other means "P" document published prior to the international filing date but later than the priority date claimed "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art "&" document member of the same patent family		
Date of the actual completion of the international search 10 February, 2010 (10.02.10)		Date of mailing of the international search report 23 February, 2010 (23.02.10)
Name and mailing address of the ISA/ Japanese Patent Office		Authorized officer
Facsimile No.		Telephone No.

**REFERENCES CITED IN THE DESCRIPTION**

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- JP 2003003237 A [0006]
- JP 2005281717 A [0006]